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Amendments to the Specification

Example 2

Please replace the first paragraph under Example 2, beginning at page 11 of the specification, line 5, with the following paragraph:

–0.183 grams of a copolymer of poly(ethoxytriethylene glycol acrylate-random-t-butyl methacrylate), (mole ratio of 30:70 of monomers, Mn=10,400, and a polydispersity, PD=2.8), 0.045 grams of DP=5 homopolymer of t-butyl methacryllate, 0.081 grams CyraCure® UVI-6976 (Dow Chemical), and 0.13 milligrams Quanticure ITX (Aldrich) and 0.13 mg of 2,3-Diazabicyclo[3.2.2]non-2-ene, 1,4,4-trimethyl-, 2,3-dioxide (TAOBN) (Hampford Research, Inc. P.O. Stratford, Connecticut 06615) were dissolved to a clear solution in 0.424 grams of PGMEA. Using a 2 mil doctor blade, the solution was cast on a glass plate and allowed to air dry for 10 minutes. The film was then dried for 2 min at 70 deg C hot plate. The film was exposed with approximate 600 mJ/cm² broad band UV light using a 20 micron photomask, then heat treated on a hot plate at 120 deg C for 2 min. The imaged part was developed by dipping into a 0.5 % sodium carbonate solution. The film was washed with deionized water for 1 min., then dried on a hot plate at 70 deg C for 1 min. The remaining film was flood exposed with 600 mJ/cm² then heat treated at 120 deg C for 2 mins. The remaining film could be washed out with a 0.5 % sodium carbonate solution.---

Example 3

Please replace the first paragraph under Example 3, beginning at page 11 of the specification, line 26, with the following paragraph:

–0.183 grams of a copolymer of poly(ethoxytriethylene glycol acrylate-random-t-butyl methacrylate), (mole ratio of 70:30 of the monomers, Mn=10,400), 0.045 grams of DP=5 homopolymer of t-butyl methacryllate, 0.081 grams CyraCure® UVI-6976 (Dow Chemical), and 0.13 milligrams Quanticure ITX (Aldrich) and 0.02 g of BHT were dissolved to a clear solution in 0.424 g of PGMEA. Using a 2 mil doctor blade, the solution was cast on a glass plate and allowed to air dry for 10 minutes. The film was then dried for 2 min at

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70 deg C hot plate. The film was exposed with approximate 600 mJ/cm² broad band UV light using a 20 micron photomask, then heat treated on a hot plate at 120 deg C for 2 min. The imaged part was developed by dipping into a 0.5 % sodium carbonate solution. The film was washed with deionized water for 1 min., then dried on a hot plate at 70 deg C for 1 min. The remaining film was flood exposed with 600 mJ/cm² then heat treated at 120 deg C for 2 mins. The remaining film could be washed out with a 0.5 % sodium carbonate solution.--